PATENT APPLICATION

RESPONSE UNDER 37 CFR §1.11 EXPEDITED PROCEDURE **TECHNOLOGY CENTER ART UNIT 2813**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Akira SHIMOKOHBE et al.

Group Art Unit:

Application No.: 09/556,795

Examiner:

Asok K. Sarkar

Filed: April 25, 2000

Docket No.:

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106096

For:

A THIN FILM-STRUCTURE AND A METHOD FOR PRODUCING THE SAME

AMENDMENT AFTER FINAL REJECTION UNDER 37 CFR §1.126

Director of the U.S. Patent and Trademark Office Washington, D.C. 20231

Sir:

AMENDMENT AFTER FINAL REJECTION UNDER 37 CFR §1. 126
or of the U.S. Patent and Trademark Office
ington, D.C. 20231

In reply to the Office Action mailed November 30, 2001, please amend the aboveidentified application as follows:

IN THE CLAIMS:

Please replace claim 3 as follows:

(Twice Amended) A method for producing a thin film-structure

comprising the steps of:

forming on a substrate a thin film made of an amorphous material having a supercooled liquid phase region,

heating the thin film to a temperature within the supercooled liquid phase region so that the thin film has a viscous flow between $10^8 \cdot 10^{13}$ Pa·S and thereby deforming the thin film to a given shape without the use of an external force, and